

DIGITALIZATION

AUTOMATION

ELECTRIFICATION



Making mobile machines perform

Sensors & Measurement Systems

Measurement Systems



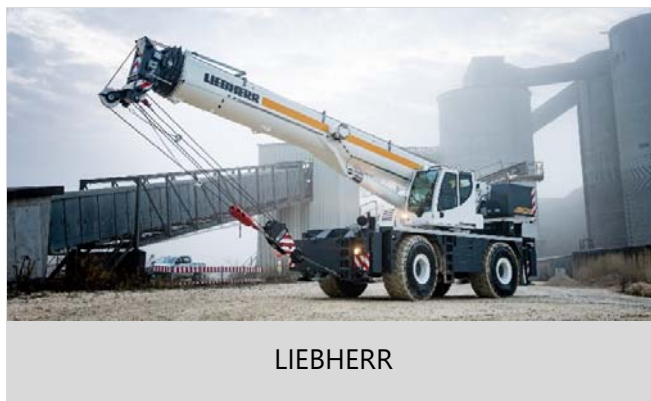
Products

<p>Pressure Sensors</p>  <p>F-Series M-Series P-Series</p>	<p>Position Sensors</p>  <p>FELIX</p>	<p>Inclination & Gyro Sensors</p>  <p>NGS</p>	<p>Strain Sensors</p>  <p>DMS</p>	<p>Temperature Sensors</p>  <p>T-Series</p>
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Technologies

SIL2		CAN			Thinfilm Technology
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References



Sensors for **mobile machines and automotive applications**



M-Series **pressure**

- range up to 2000 bar
- operable from -40 to +150°C
- analog or with CAN-bus
- SENT (SAE J2716) *)
- welded, stainless steel pressure cell
- E1 approval
- high media compatibility incl. H₂

*) availability planned for Q2/2019



T-Series **temperature**

- range from -40 to +150°C
- CAN (J1939 & CANopen)



automotive **customized**

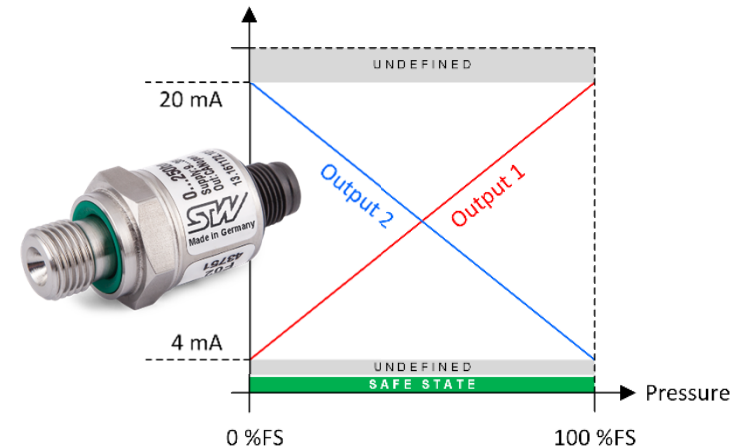
- development according to customer requirements
- qualified production processes
- custom specific bus systems
- also for applications requiring PLx, SILx and ASILx

Pressure Sensors & Switches for **safety-related applications**



F-Series **pressure switch**

- PLd (EN ISO 13849-1)
- ranges up to 1000 bar
- operable from -40 to +85°C
- two switching outputs or one switching output and one current output
- welded, stainless steel pressure cell



F-Series **pressure sensor**

- PLd (EN ISO 13849-1) | SIL 2 (IEC 61508)
- ranges up to 1200 bar
- operable from -40 to +85°C
- two analog outputs (contrary)
- welded, stainless steel pressure cell
- made-to-order

Pressure Cells (in-house product, mainly used)



Type **OEM**

- measuring range from 25 to 3000 bar
- temperature ranges from -40 to +200°C
- compensated zero
- hysteresis <0.1% FS
- integrated temperature meander
- stainless steel precision part
- suitable for wire-bonding or soldering
- long term stability <0.2% FS p.a. (ref. cond.)



Type **OPTI**



- measuring range from 25 to 2000 bar
- temperature ranges from -40 to +200°C
- hysteresis <0.2% FS
- integrated temperature meander
- stainless steel precision part
- suitable for wire-bonding
- one size up to 1.200bar
- long term stability <0.2% FS p.a. (ref. cond.)

Measurement systems for **mobile machines and automotive applications**



NGS **inclination & gyro**

- angular velocity and acceleration / inclination
- CAN interface
- custom variants available



DMS **strain gauge**

- scalable range
- easy mounting
- analog electrical signal or CAN-interface
- fast exchange when service needed



FELIX **position**

- measures a linear displacement of up to 20 mm
- particularly robust
- highly resistant to contamination at the measuring point
- high linearity

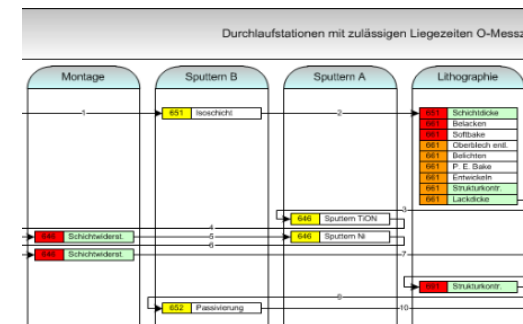
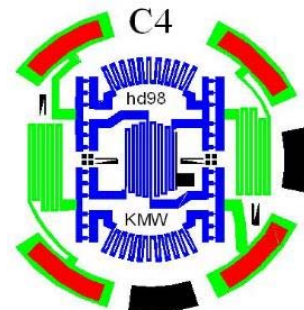
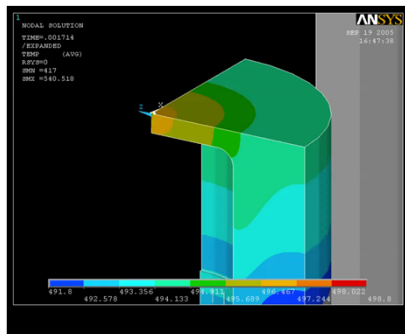
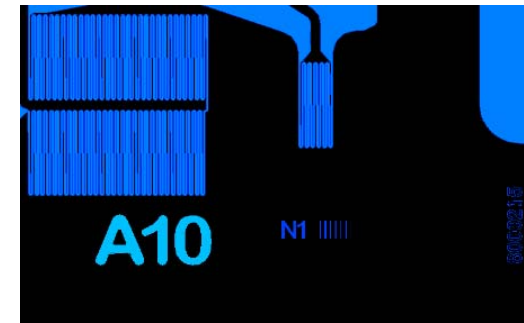
Our Customers



Thin Film Technology | competence overview



- Design, development & production of custom Thin Film Sensors
 - Material selection (substrate & thin film materials)
 - Application-oriented electrical and mechanical dimensioning
 - FEM-analysis
 - Multilayer mask design
 - Individual process design
 - Production in the KMW Class ISO 5 clean room



Thin Film Technology | **processes & equipment**



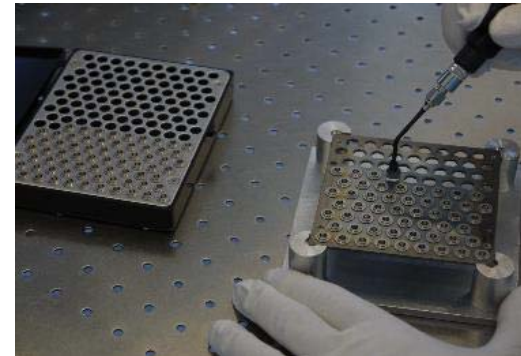
- Preparation – **Polishing**

- Membrane thicknesses with an accuracy down to $\pm 23 \mu\text{m}$
- Substrate heights within $30\mu\text{m}$, allowing large numbers of single pieces in one thin film production cycle (KMW standard: 105 pcs./cycle)

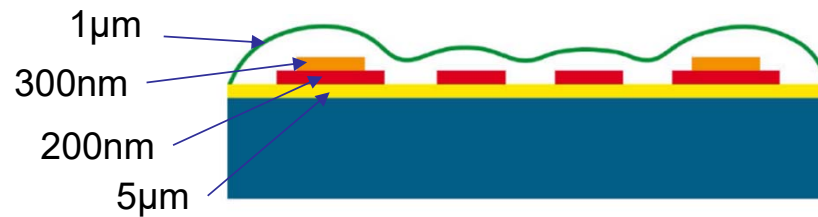


- **Batch Assembly**

- Objective: Efficient usage of the available space in our Sputtering/PECVD devices
- Small pieces are assembled in production batches
- Larger pieces can be coated separately or with an individual batch design

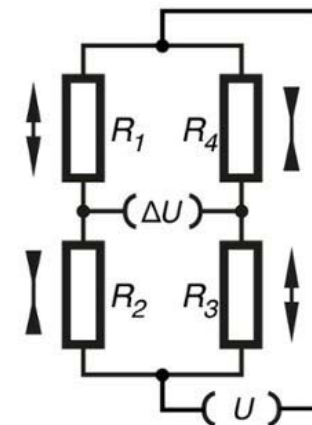
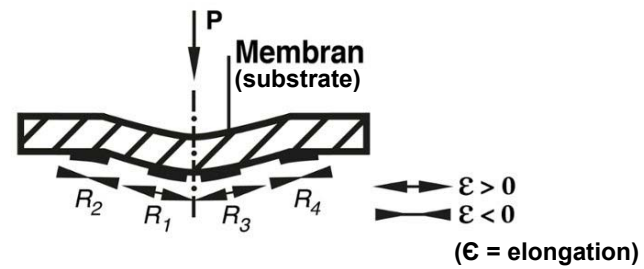


■ Package on a pressure capsule



Thin film structures for sensor applications

- Passivation layer
- Contact pads
- Functional layer
- Insulation layer
- Substrate

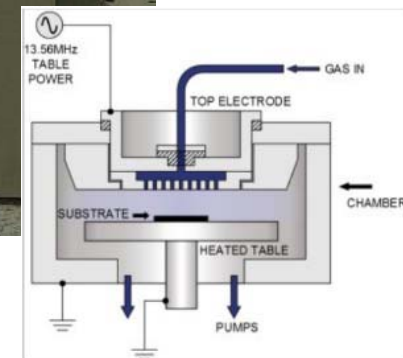


Thin Film Technology | processes & equipment



■ Isolation/Passivation Layer

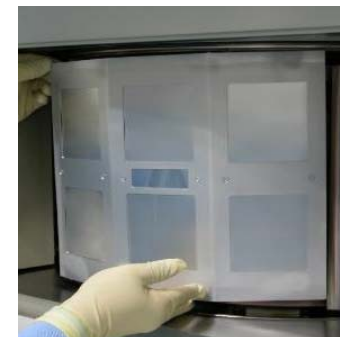
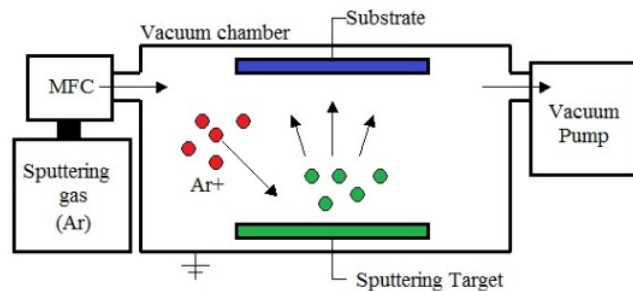
- PECVD - process
- Insulation materials: SiO_2 , Si_3N_4 , SiON
- Polyimide for multilayer designs
- Thickness: 0.6 up to 5 μm
- Highly resistant (100 $\text{G}\Omega$ or higher)



Thin Film Technology | processes & equipment



- **Functional Layers & Contact Pads (DC- and Pulsed DC-Sputtering)**
 - Multilayer-designs with vias
 - Sputter-Targets: NiCrAl, Cu, Cr, Ni, Ti, Gases: Ar, N₂, O₂
 - Functional materials (thickness: up to 1 μm)
 - Ni → high TCR, solderable
 - TiON (reactive process) or NiCrAl → high GF
 - Cu and others as interlayer or conductor if GF & TCR is not needed



Thin Film Technology | **processes & equipment**



■ **Lithography**

- Spin- and spray-coater
 - Photoresist is applied to the substrate
 - Thickness 3..6 μm
 - Positive and negative photoresist

- Exposure device / mask-aligner
 - Photomasks are aligned with the substrates
 - Structure is mapped on the photoresist
 - Hg-Lamps with 350 nm to 450 nm wavelengths

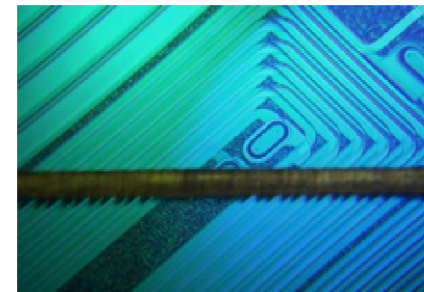
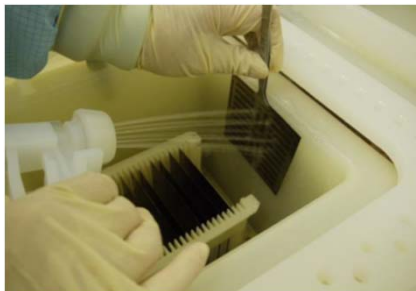


- **Structuring**

- Wet-chemistry

- Substrate cleaning with US-processes and QDR-sink
 - Developing of exposed photoresist with KOH
 - Metal etching with FeCl_3 , H_2SO_4 , $\text{K}_3\text{Fe}(\text{CN})_6$
 - Lift-Off process with KOH

- Structure scale down to 12 μm , structure distance down to 8 μm

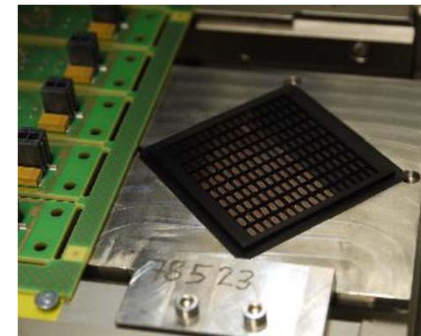
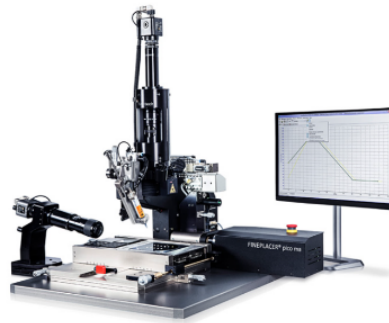
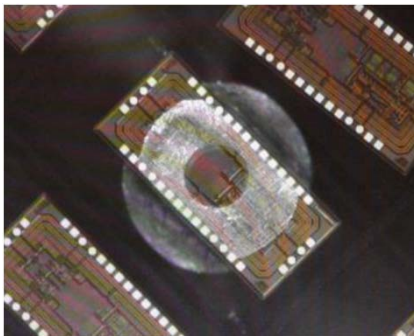


Sensor packaging | **chip bonding**



- **Chip bonding**

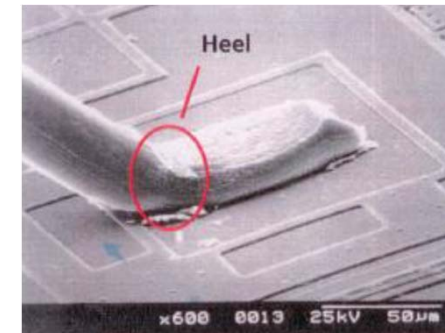
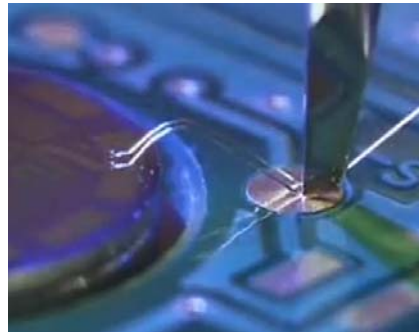
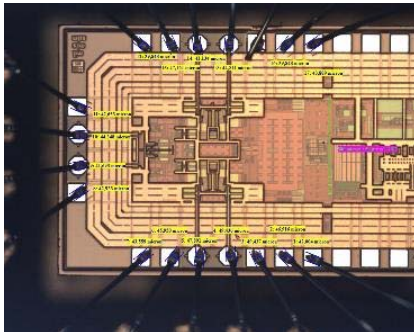
- Die-bonder for chip-mounting
- Adjustable bond force (0 N up to 30 N)
- 5 μm placement accuracy
- Electrical and/or thermal conductive chip connections
- Chip molding



Sensor packaging | **wire bonding**



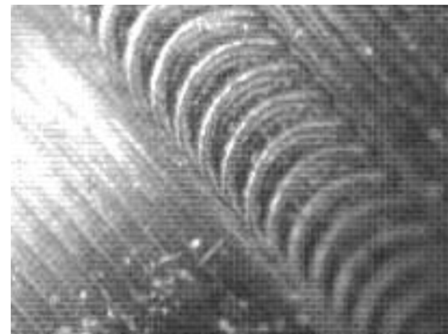
- **Wire bonding**
 - 2 fully automatic wire bonding machines
 - 2 tabletop semi-automatic wire bonding machines
 - Wedge-wedge bonding
 - Deep-access bond-head for narrow geometries
 - 25 μm / 50 μm AlSi 1% wires



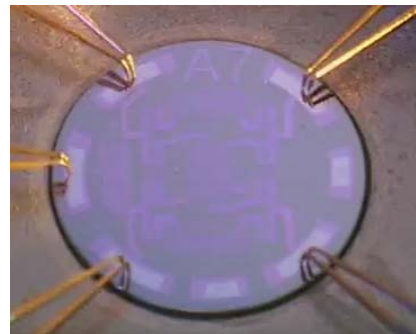
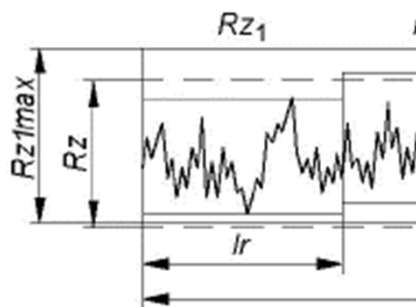
Sensor packaging | **backend packaging**



- **Laser welding**
 - NdYag pulse-laser with 7,5kW
 - Used for capsule welding and housing
 - Overlapped welding dots for hermetic connections
- **Resistance Welding**
 - Inverter with up to 36kA
 - Integrated process control for best results



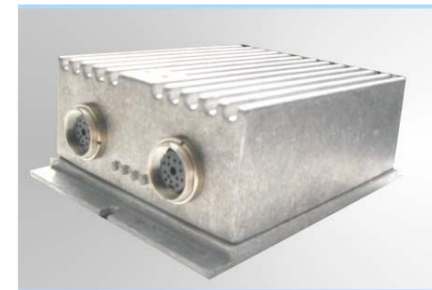
- Detailed process monitoring for thin film process steps, e.g.
 - Surface profiler and interferometer for membranes, layer thickness and roughness measurements
 - Surface resistivity measurements
 - Layer tension and adhesion tests
- Electronics: AOI, ICT, X-ray
- 100% electrical test on several production levels
- In-house EMC chamber for pre-certification measurements



Products | In-cylinder pressure sensors



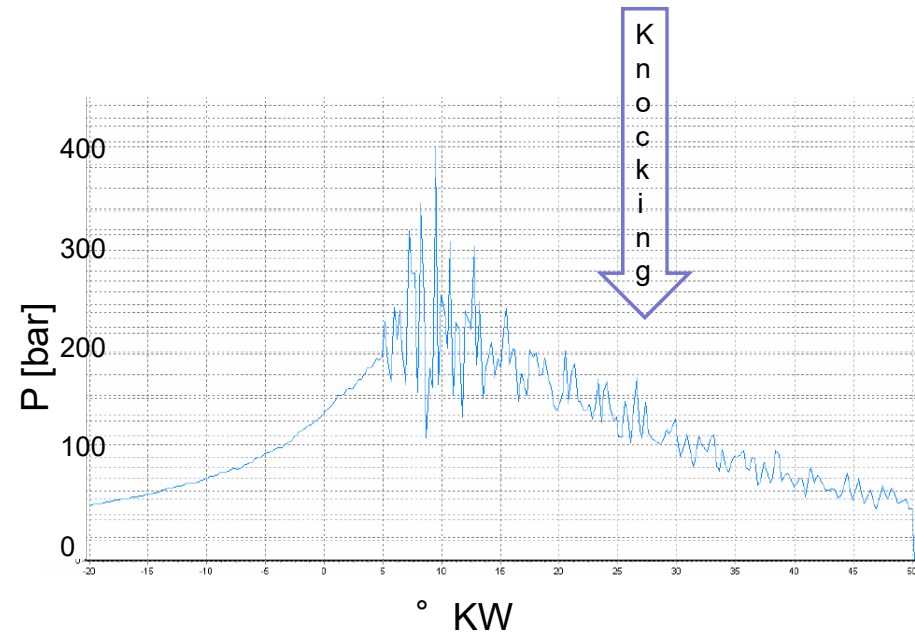
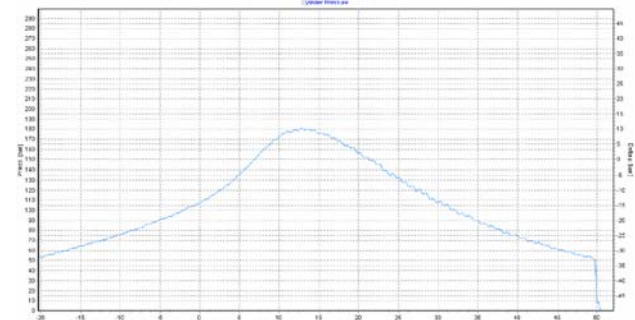
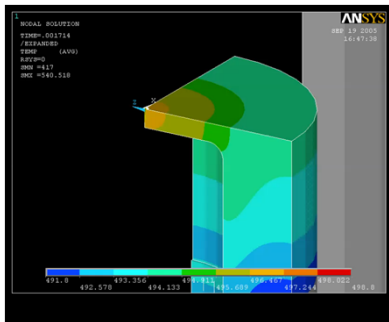
- Wiedemann-sensors have been used for 20 years in gas and diesel engines
- High-temperature and permanent load-resistant by using
 - own thin-film technology
 - High-strength nickel-alloy for the measuring elements
- Deviation of the span < 0,5 % after 20,000 operation hours (test in 2012)
- Vibration tests up to 50g acceleration
- Reducing of the thermo shock by patent-registered flame protection
- Standard pressure connection: M14x1.25, M10x1
- Diameter down to 8 mm possible
- Data acquisition and conditioning with a resolution up to 0.1° KW



Products | In-cylinder pressure sensors



- Permanent temperature > 250° C
- Peak temperature > 350° C
- High fatigue strength
- Vibration resistant
- Low measurement deviation (Thermal shock)
- Low drift in span
- Fast data acquisition
- Fast supply of control variable
- Inside existing design space

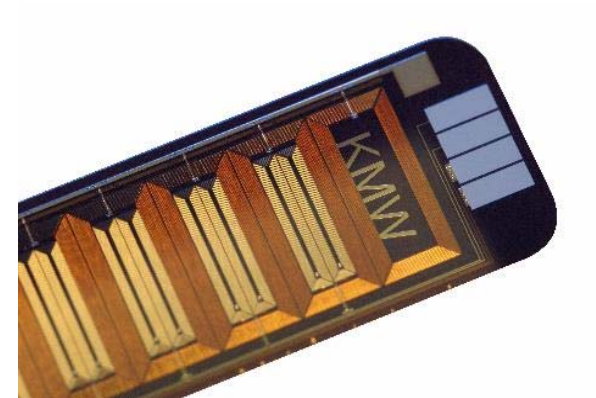
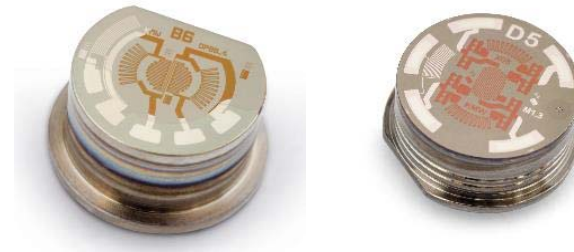


Products | **measuring elements**



- OEM Pressure capsules for hardest environments
 - Stainless steel with applied thin film structures
 - Integrated temperature meander
 - Pressure range from 10 to 3000 bar
 - Temperature range from -40 to +200 degreeC

- Inductive path sensors
 - Stainless steel substrate
 - 5 metal layers
 - Microvias
 - 8 meters overall conductor length on a 30x5 mm substrate



Products | RnD & prototypes

